

**RECEIVED
CENTRAL FAX CENTER****SEP 20 2005****PATENT APPLICATION
Mo6646D
LeA 34,283****IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

| | | |
|--|---|----------------------------|
| APPLICATION OF |) | GROUP NO.: 1755 |
| KRISTINA VOGT ET AL |) | EXAMINER: M. A. MARCHESCHI |
| SERIAL NUMBER: 10/680,831 |) | |
| FILED: OCTOBER 7, 2003 |) | |
| TITLE: ACIDIC POLISHING SLURRY FOR THE CHEMICAL-MEC- HANICAL POLISHING OF SiO ₂ ISOLATION LAYERS |) | |

AMENDMENT

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

Sirs:

This is in response to the Office Action dated July 20, 2005. Please amend the application as follows. A separate Request for Continued Examination (RCE) Transmittal is being submitted simultaneously herewith.

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an enveloped addressed to: Commissioner for Patents, Alexandria, VA 22313-1450 or facsimile transmitted to the USPTO on the date below.

Diderice van Eyll, Reg. No. 38,641

Name of applicant, assignee or Registered Representative

Signature

September 20, 2005

Date